

AP20 Rec'd PCT/PTO 07 AUG 2006

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Takeshi HIRABAYASHI et al.

New U.S. National Phase of PCT/JP2005/004403

Filed: August 7, 2006

Docket No.: 128996

For: EXHAUST GAS PURIFYING CATALYST, METAL OXIDE PARTICLE AND
PRODUCTION PROCESS THEREOFINFORMATION DISCLOSURE STATEMENTCommissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Pursuant to 37 CFR §1.56, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached PTO-1449. Unless otherwise indicated herein, one copy of each reference is attached. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

- ☒ 1. This Information Disclosure Statement is being filed (a) within three months of the U.S. filing date of this non-CPA application, OR (b) before the mailing date of a first Office Action on the merits in the present application. No certification or fee is required.
- ☒ 2. Relevance of one or more non-English language reference is discussed in the present specification. See References 10-16.
- ☒ 3. One or more reference cited herein was cited in the International Search Report. An English language version of the International Search Report is attached for the Examiner's information. See References 1 and 6-9.
- ☒ 4. In accordance with 37 CFR §1.98(a)(2)(ii), copies of any U.S. patents and patent application publications are not attached.
- ☒ 5. An English language Abstract of one or more non-English language reference is attached hereto. See References 7 and 9-16.

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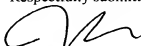


6. A computer-generated English language translation of one or more Japanese Patent Publication cited herein has been obtained from the website of the Japanese Patent Office ([<http://www.jpo.go.jp>]), and is attached, but has not been reviewed for accuracy. See References 10-16.



7. Reference 2 corresponds to reference 6. Reference 8 corresponds to reference 5. References 3 and 4 correspond to reference 9.

Respectfully submitted,



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INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

10/588603

APPLICANTS
Takeshi HIRABAYASHI et al.

FILING DATE
August 7, 2006

U.S. PATENT DOCUMENTS

Examiner Initials	Cite No.	Document Number	Date	Name
/SC/	1	5,439,865	8/8/1995	Abe et al.
/SC/	2	5,334,570	6/2/1994	Bcausigneur et al.
/SC/	3	5,352,646	10/4/1994	Blanchard et al.
/SC/	4	5,232,889	8/3/1993	Blanchard et al.
/SC/	5	2002/0049137 A1	4/25/2002	Morikawa et al.

FOREIGN PATENT DOCUMENTS

Examiner Initials	Cite No.	Document Number	Date	Country	With English Abstract	With English Translation
/SC/	6	EP 0 524 643 A	1/27/1993	Europe		
/SC/	7	FR 2 836 067 A	8/22/2003	France	X	
/SC/	8	EP 1 175 935 A	1/30/2002	Europe		
/SC/	9	EP 0 430 744 A	6/5/1991	Europe	X	
/SC/	10	JP A 8-103650	4/23/1996	Japan	X	X
/SC/	11	JP A 8-109020	4/30/1996	Japan	X	X
/SC/	12	JP A 8-109021	4/30/1996	Japan	X	X
/SC/	13	JP A 2000-319019	11/21/2000	Japan	X	X
/SC/	14	JP A 2001-89143	4/3/2001	Japan	X	X
/SC/	15	JP A 10-194742	7/28/1998	Japan	X	X
/SC/	16	JP A 10-258232	9/29/1998	Japan	X	X

OTHER DOCUMENTS

Examiner Initials	Cite No.	(Including Author, Title, Date, Pertinent Pages, etc.)

EXAMINER /Stefanie Cohen/

DATE CONSIDERED
08/13/2008

Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.